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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10090465	FILING DATE 03/04/2002	CLASS 430	SUBCLASS	GAU	EXAMINER Young
**APPLICANTS: Livesay William; Ross Matthew; Ross Richard;					
**CONTINUING DATA VERIFIED: THIS APPLN CLAIMS BENEFIT OF 60/338,958 12/07/2001					
** FOREIGN APPLICATIONS VERIFIED:					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO EV-1	
Verified and Acknowledged Examiners's initials					
TITLE : Method and apparatus for modification of chemically amplified photoresist by electron beam exposure					
U.S. DEPT. OF COMM. (PAT. & TM.) PTO-436L (Rev. 12-94)					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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